

Self heating and nonlinear current-voltage characteristics in bilayer graphene

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We demonstrate by experiments and numerical simulations that the low-temperature current-voltage characteristics in diffusive bilayer graphene (BLG) exhibit a strong superlinearity at finite bias voltages. The superlinearity is weakly dependent on doping and on the length of the graphene sample. This effect can be understood as a result of Joule heating. It is stronger in BLG than in monolayer graphene (MLG), since the conductivity of BLG is more sensitive to temperature due to the higher density of electronic states at the Dirac point.

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I. INTRODUCTION

Two-dimensional graphene in its monolayer and bilayer forms can exhibit rather different electronic characteristics.^{1,2} In monolayer graphene (MLG) the valence and conductance bands touch each other at two inequivalent Dirac points in the Brillouin zone, around which the bands are linear. Thus the density of states (DOS) also vanishes linearly around these points, where the Fermi energy of charge-neutral graphene is located. In the most common (Bernal) stacking of bilayer graphene (BLG) the two layers are electronically coupled such that the two linear bands of the individual layers mix to form four bands, the lower of which are parabolic around the Dirac points. In this case the DOS around these points is approximately constant.

This difference gives rise to different charge screening and transport properties for the two types of graphene. In particular, the temperature dependences for the conductivity of diffusive MLG and BLG around the charge-neutrality point (CNP) differ.³⁻⁸ In both cases, thermal excitation of quasiparticles from the valence to the conduction band (i.e. thermal creation of electron-like and hole-like charge carriers) increases the conductivity with temperature, as is typical for semiconductors and insulators. However, due to differences in the DOS, in MLG the conductivity at CNP grows only quadratically with temperature, while in BLG it increases linearly.⁵

In this paper we show how this difference of MLG and BLG is reflected in the current-voltage ($I(V)$) characteristics of diffusive graphene. For MLG it is known that the $I(V)$ characteristics tend to be linear at low bias voltage V and have a tendency to saturate at higher voltages due to scattering of electrons from optical phonons.^{9,10} Close to CNP the $I(V)$ at small V can become superlinear as a result of Zener-Klein tunneling between the valence and conduction bands, especially in low-mobility samples.¹¹ By measuring the $I(V)$ curves of both MLG and BLG on a SiO_2 substrate in a two-terminal configuration, we show that in BLG the $I(V)$ characteristics have a much stronger tendency for superlinearity at $V \lesssim 0.1$ V, which we associate with an increase of the

conductivity due to self heating (Joule heating). This effect is only weakly dependent on the level of doping and on the length of the sample. We confirm this interpretation with numerical simulations using a semiclassical model based on Boltzmann theory for a diffusive two-dimensional (2D) system in quasiequilibrium. The model takes into account electron scattering from charged impurities, the band-bending effects due to charge doping by the metallic source and drain electrodes,¹²⁻¹⁴ uniform impurity doping, as well as nonuniform doping by a gate electrode. For MLG the Joule-heating-related nonlinearity is found to be weak, which is consistent with previous experiments and calculations.⁹⁻¹¹

The paper is organized as follows. In Sec. II we introduce the theoretical model, Sec. III describes the experimental results and compares them to theory, and in Sec. IV we end with some discussion of other mechanisms for current nonlinearities. Details of the model are given in the Appendixes. In App. A solution of the electrostatic part of the problem in terms of a Green function is detailed. Appendix B discusses the modeling of the impurity scattering and gives expressions for the charge density and the transport coefficients for MLG and BLG. Finally, in Sec. C we discuss analytic semiclassical results for the temperature dependence of the conductance of a p - n junction, which can form in the graphene close to the metallic electrodes.

II. THEORETICAL MODEL

The model geometry that we consider (see Fig. 1) is a simplification of typical experimental geometries. It consists of a two-dimensional (quasi-one-dimensional) channel coupled to two transport electrodes (l and r) as well as a back gate electrode (bg). In this geometry we solve for the electrostatic potential together with transport equations for the quasiparticles in the channel.

Our semiclassical transport theory assumes a diffusive 2D electron system in quasiequilibrium,¹⁵ such that the quasiparticle distribution is described by a local chemical potential $\mu(x)$ and a local temperature $T(x)$. A third unknown field is the electrostatic potential $\varphi(x)$ in the

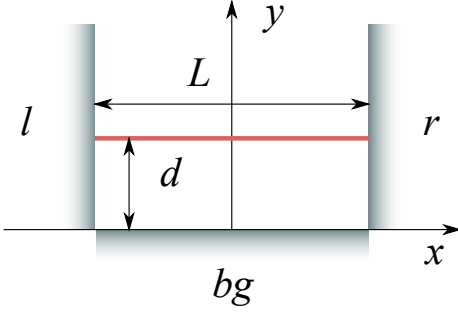


FIG. 1. The rectangular geometry considered in the model. l and r depict the left and right (source and drain) electrodes, while bg is a back gate electrode. All three are held at different constant potentials, ϕ_l , ϕ_r , and ϕ_{bg} , respectively. The 2D channel, of length L , is at a distance d from the back gate. For simplicity the regions below and above the channel are assumed to be occupied by the same dielectric medium with permittivity ε .

channel ($y = d$), which shifts the energy $E_D(x)$ of the local Dirac point such that $E_D(x) = -e\varphi(x)$. The three fields $\varphi(x)$, $\mu(x)$, and $T(x)$ are solved from the equations

$$\begin{aligned} \varphi(x) = & \int_{-L/2}^{L/2} d\xi G(x, d; \xi, d) e[n(\xi) - n_{dop}]/\varepsilon \\ & + \sum_{X=l,r,bg} \psi_X(x, d) \phi_X \\ & [\sigma(x)\mu'(x)/e + \gamma(x)T'(x)]' = 0, \\ & -[\alpha(x)\mu'(x)/e + \kappa(x)T'(x)]' = P_J(x). \end{aligned} \quad (1)$$

Here prime denotes the x -derivative, G is the Green function of the Laplace operator, $\psi_X(x, y)$ is the “characteristic function” for electrode X (see App. A), and $\varepsilon = \varepsilon_r \varepsilon_0$, where ε_r and ε_0 are the relative and vacuum permittivities. Further, $n(x)$ is the two-dimensional charge density in units of the electron charge $-e$ (App. B), and n_{dop} is a phenomenological doping density that describes the doping effect by impurities, which is assumed to be constant. (Thus, charge puddles^{16,17} are not described — see below for discussion). The factors $\sigma(x)$ and $\kappa(x)$ are the charge and thermal conductivities, respectively, while $\alpha(x)$ and $\gamma(x)$ are the thermoelectric transport coefficients, satisfying $\alpha(x) = T(x)\gamma(x)$. These factors are inversely proportional to the impurity density n_{imp} , which is taken to be another constant parameter independent of n_{dop} (App. B). The quantities $n(x)$, $\sigma(x)$, $\kappa(x)$, $\gamma(x)$, and $\alpha(x)$ all depend on $\varphi(x)$. Finally, $P_J(x) = j(x)(\mu'(x)/e)$ is the Joule power per area, with $j(x) = \sigma(x)\mu'(x)/e + \gamma(x)T'(x)$ being the electric current density, which is conserved, $j(x) \equiv j$. The total current through a system of finite width $W \gg L, d$ is $I = jW$.

The boundary conditions at $x = \pm L/2$ are chosen to be

$$\begin{aligned} \phi_l = -V, \quad \phi_r = 0 \\ \mu(-L/2) = eV + \mu_{eq}, \quad \mu(+L/2) = \mu_{eq} \\ T(-L/2) = T(+L/2) = T_0. \end{aligned} \quad (2)$$

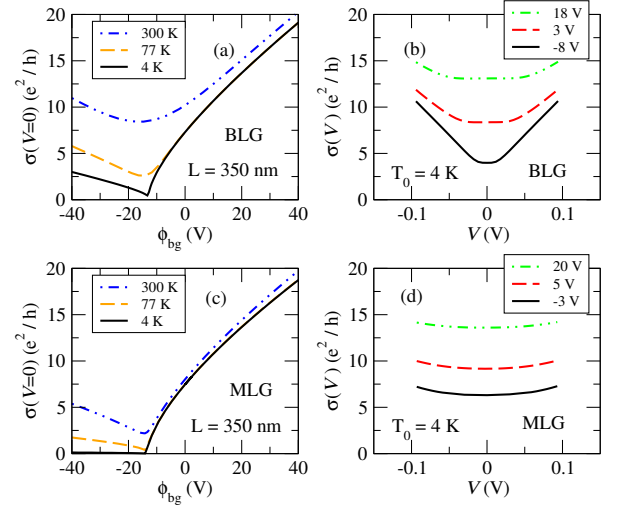


FIG. 2. Results for BLG (a,b) and MLG (c,d) with parameter $L = 350$ nm, $\mu_{eq} = 0.05$ eV, $n_{dop} = 10.0 \cdot 10^{15} \text{ m}^{-2}$, $\varepsilon_r = 4.0$, $d = 210$ nm. Additionally for BLG $n_{imp} = 7.0 \cdot 10^{16} \text{ m}^{-2}$, and for MLG $n_{imp} = 2.5 \cdot 10^{15} \text{ m}^{-2}$. (a,c) Linear-response conductivity $\sigma(V=0) = (L/W)(dI/dV)_{V=0}$ at three temperatures and (b,d) the corresponding finite- V differential conductivity $\sigma(V) = (L/W)(dI/dV)$ for $T_0 = 4$ K at indicated gate voltages ϕ_{bg} .

which correspond to a voltage bias V , assuming negligible contact resistance, the right-hand electrode to remain grounded, and both electrodes to remain at the bath temperature T_0 . The finite equilibrium chemical potential $\mu_{eq} \neq 0$ describes the effects of the work function mismatch and the resulting charge transfer between the graphene and the electrodes, with $\mu_{eq} > 0$ ($\mu_{eq} < 0$) leading to n -type (p -type) doping.¹⁴

The first of Eq. (1) is the Poisson equation written as an integral equation at $y = d$. The second and third describe current conservation and heat balance, respectively. Note that in order to keep the model simple, we do not include electron-phonon coupling and thus the Joule power is dissipated only via diffusion.¹⁵ This should be reasonable first approximation at bias voltages V well below optical phonon energies.¹⁸

In Fig. 2 we show typical results obtained from the model for BLG and MLG with parameters obtained from the fit to (the gate dependence of) our BLG experiments in Sec. III. It is to be noted that the aspect ratio $L/d = 1.7$ is far too small for a simplified parallel-plate capacitor model to work properly in the geometry of Fig. 1, and a full numerical solution of Eqs. (1) is needed. The fields obtained as their solutions are very nonuniform, as shown for BLG in Fig. 3.

The upper panels of Fig. 2 are for the case of BLG. Fig. 2(a) shows the gate dependence of the linear-response conductivity $\sigma(V=0) = (L^{-1} \int_{-L/2}^{L/2} \rho(x') dx')^{-1}$, where $\rho(x) = 1/\sigma(x)$ is the resistivity. Due to finite positive doping density ($n_{dop} > 0$) the point of minimal conductivity (the apparent “CNP”) is shifted to $\phi_{bg} = \phi_{bg,min} \approx$

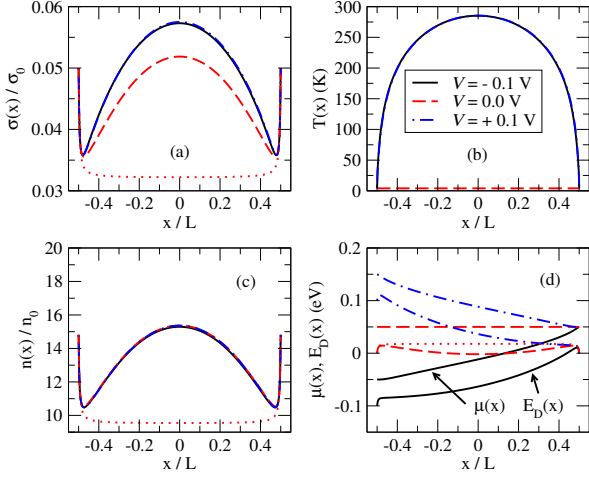


FIG. 3. Bias dependence of the field profiles for n -type BLG at gate voltage $\phi_{bg} = 8$ V: (a) conductivity σ , (b) temperature T (c) charge density n (d) chemical potential μ and the local Dirac point E_D (higher and lower curve, respectively). Solid, dashed, and dash-dotted curves are for $V = -0.1, 0.0$, and 0.1 V, respectively. Dotted lines show additionally σ , n , and E_D in equilibrium at $\phi_{bg} = 0$; here $n(x=0) \approx n_{dop}$. The parameters are as in Fig. 2, and we have defined the units $\sigma_0 = C_{BLG}E_0$ and $n_0 = (\varepsilon/d)E_0/e^2$, where $E_0 = 1$ eV (for C_{BLG} , see App. B).

-13 V and as result of the lead-doping effect ($\mu_{eq} > 0$), the gate dependence is asymmetrical around the CNP.¹² Since the lead-doping is of n type, at $\phi_{bg} > \phi_{bg,min}$ the BLG is of n type everywhere. However, for $\phi_{bg} < \phi_{bg,min}$ two p - n junctions appear,¹² and the BLG becomes of n - p - n type. While for $\phi_{bg} > \phi_{bg,min}$ the dependence on temperature is relatively weak, for $\phi_{bg} \approx \phi_{bg,min}$ it is roughly linear: $\sigma(V=0) \propto T$ (Ref. 5). For $\phi_{bg} \ll \phi_{bg,min}$, where the p - n junctions dominate the resistance, it can be shown that approximately $\sigma(V=0) \propto -1/\ln(T)$ as $T \rightarrow 0$ (App. C). However, the theory is valid only when all parts of graphene remain far from the local CNP. This is because charge puddles, quantum-mechanical effects (see App. C), and a possible gap in the BLG spectrum are not taken into account. Thus, we mainly concentrate on the gate voltages $\phi_{bg} > \phi_{bg,min}$.

Fig. 2(b) shows the differential conductivity $\sigma(V) = (L/W)(dI/dV) = L(dj/dV)$ as a function of V for a few gate voltages $\phi_{bg} > \phi_{bg,min}$ at low bath temperature. Note that the $\sigma(V)$ curves are nearly symmetric [$\sigma(-V) \approx \sigma(V)$], although there are small deviations, which are due to the asymmetrical choice of the boundary conditions and the presence of the gate electrode. The increase of $\sigma(V)$ at finite V signifies a superlinear contribution to the $I(V)$ curve: $I(V) \approx G_1V + G_2V^2$ ($V > 0$) with $G_2 > 0$. This superlinearity is strongest close to the CNP, where the conductivity of BLG is most sensitive to temperature (see Eq. (B5)). In fact, the increase of the conductivity with voltage [see Fig. 3(a)] is entirely due to heating, which leads to maximal temperatures of $T(x) \sim 300$ K at $V = 0.1$ V [Fig. 3(b)]. The

charge density $n(x)$ for example, remains almost independent of V [Fig. 3(c)]. Indeed, the density is of the form $n(x) = \hat{n}(\mu(x) - E_D(x))$ (App. B), and $\mu(x) - E_D(x)$ remains close to its value at $V = 0$ everywhere [Fig. 3(d)]. Thus the bias voltage “gates” the graphene very little. The dotted lines in Fig. 3 additionally show the results at equilibrium, with $\phi_{bg} = 0$. The fast transients close to the electrodes are due to the doping by the leads. This doping is not restricted only to the region on the order of a screening length ~ 1 nm (Sec. B) from the leads, but is actually long-ranged.^{14,19}

The lower panels Fig. 2(c,d) show equivalent results for MLG, where the impurity density n_{imp} has been chosen so that the conductivities are of a similar magnitude as for BLG. The temperature-dependence of $\sigma(V=0)$ for $\phi_{bg} \gtrsim \phi_{bg,min}$ is now clearly even weaker. For $\phi_{bg} \approx \phi_{bg,min}$ it is quadratic, $\sigma(V=0) \propto T^2$ (Ref. 5), and for $\phi_{bg} \ll \phi_{bg,min}$ linear, $\sigma(V=0) \propto T$ (App. C). Correspondingly, the increase of the $\sigma(V)$ at $\phi_{bg} > \phi_{bg,min}$ is much weaker. This is consistent with the fact that the $I(V)$ curves measured for MLG are typically linear or even sublinear, except close to CNP in low-mobility samples, where Zener-Klein tunneling is of importance.¹¹ In the case of MLG the “gating” effect of the bias voltage is somewhat larger due to the longer screening length, but remains also weak.

Here we have concentrated on short samples, with $L/d \sim 1$. In the considered model geometry the gate dopes the graphene quite weakly at distances on the order of d from the ends. Additionally, the center of the graphene heats more than the ends. Therefore at $\phi_{bg} > \phi_{bg,min}$ the ends tend to dominate the resistance [Fig. 3(a)]. When $L \gg d$, the parallel-plate limit is approached, where $n(x)$ and $\sigma(x)$ become uniform, with $\mu(x)$ and $E_D(x)$ roughly linear. One may then simplify the equations Eqs. (1) by taking $\alpha = \gamma = 0$ and using the Wiedemann-Franz law $\kappa = \mathcal{L}T\sigma$, where $\mathcal{L} = (\pi^2/3)(k_B/e)^2$, and assuming a constant σ . The temperature profile is thus approximated with $T(x) = \sqrt{T_0^2 + [1/4 - (x/L)^2]V^2/\mathcal{L}}$, which scales simply with V . The heating effect on the conductivity $\sigma(V)$ therefore depends relatively weakly on the length of the sample.

We do not pursue further simplifications or extensions of the model here, but it should be noted that the thermoelectric coefficients α and γ are not of great importance for the current nonlinearity. However, under some conditions the strong temperature gradient at the ends can also cause the conductivity to decrease at small bias voltage. A very weak sign of this is seen in the flat region of the $\phi_{bg} = 18$ V curve in Fig. 2(b). We also note that our tests with some simple models for charge puddles can reduce the width of this flat region, making nonlinearity stronger also at high gate voltages.

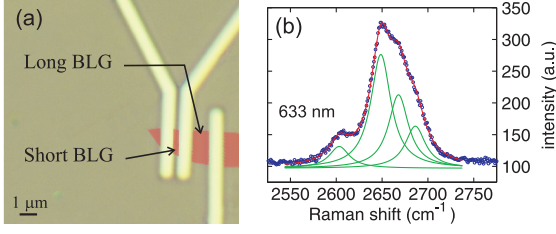


FIG. 4. (a) Optical picture of two bilayer graphene samples of lengths $L = 350$ nm and $L = 950$ nm. The BLG flake has been colored in red to enhance its visibility. (b) Raman spectrum of the corresponding bilayer graphene sheet.²⁰

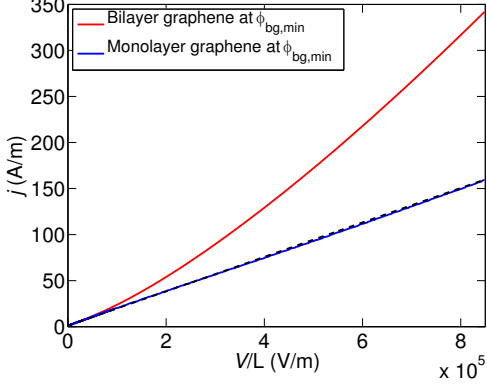


FIG. 5. Typical $I(V)$ curves for MLG and BLG at the CNP at 4.2 K. The dashed line has a slope equal to the conductivity $4.5e^2/h$ of both samples at $V = 0$. For MLG the $I(V)$ curve is linear. In BLG it is superlinear, which we associate with the Joule heating of the sample.

III. EXPERIMENTS

We have measured seven bilayer graphene samples in a two-lead configuration and found qualitatively the same transport properties for each of them. Here we focus on the results obtained on two samples from the same BLG sheet having lengths $L = 350$ nm and $L = 950$ nm, and widths $W = 900$ nm and 1550 nm, respectively (Fig. 4). The samples were contacted using Ti/Al/Ti sandwich structures with thicknesses 10 nm / 70 nm / 5 nm (10 nm of Ti is the contact layer). Three 0.6 μm wide contacts were patterned using e-beam lithography. The strongly doped Si substrate was used as a back-gate, separated by 270 nm of SiO_2 from the sample.

The $I(V)$ curve of our 0.95×1.55 μm^2 sample at 4.2 K is illustrated in Fig. 5 together with the $I(V)$ in a typical MLG sample. While the MLG result is linear,^{9,10} the BLG curve exhibits clearly superlinear behavior at small drain-source voltage V ; the nonlinearity in BLG depends relatively weakly on the gate voltage ϕ_{bg} but is largest near the CNP. The nonlinear behavior can be observed more clearly in Fig. 6(a) which displays the differential conductivity $\sigma(V) = (L/W)(dI/dV)$ of the long and short samples at a few values of ϕ_{bg} . It is seen that

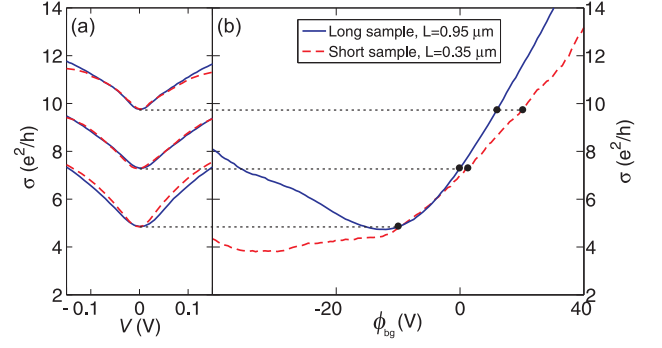


FIG. 6. The left-hand panel (a) shows the experimentally measured differential conductivity $\sigma(V)$ at finite V for both the short (dashed line) and the long (solid line) BLG sample at three pairs of gate voltages that are chosen so that the minima at $V = 0$ V for both samples coincide. The right-hand panel (b) shows the corresponding zero-bias conductivity $\sigma(V = 0)$ vs. the gate voltage ϕ_{bg} for both samples. The temperature is $T_0 = 4.2$ K.

also the length dependence of the nonlinearity at bias voltages below $V \approx 0.1$ V is weak. This supports its interpretation as a heating effect: as mentioned above, the temperature should scale with V and not, for example, the electric field V/L . Note, furthermore, that the $\sigma(V)$ curves are very symmetrical.

Figure 6(b) shows the full gate voltage dependence of the zero-bias conductivity of the short and long samples. In both samples, the minimal conductivity is located in the negative gate voltage region around -10 V. The minimum zero-bias conductivities are roughly 3.8 and $4.7e^2/h$ for the short and long sample, respectively. These are close to the value $\sim 4e^2/h$ typically found for both MLG and BLG.^{4,21} An asymmetry between the n -doped and p -doped regions is clearly visible and is more pronounced for the short sample where the conductivity is almost constant in the p -region. We interpret this electron-hole asymmetry as a sign of the leads n doping the graphene,^{12,14} so that there are p - n junctions present at larger negative gate voltages. This is consistent with expectations for Ti/Al electrodes.^{12,14} In a parallel-plate approximation the charge density is $n \approx (C_{bg}/e)(\phi_{bg} - \phi_{bg,min})$, where $C_{bg} = 1.3 \cdot 10^{-4}$ F/m². Using this we estimate from the slope of $\sigma(V = 0)$ vs. $n > 0$ for the long sample the mobility $\mu_m = \sigma/(en)$ to be at least 1500 cm²V⁻¹s⁻¹. Using this the mean free path is estimated to be $l_{mfp} = \sqrt{\pi n \hbar \mu_m}/e \lesssim 30$ nm, and thus the samples are diffusive.

We compare the raw experimental data to the theoretical results in Fig. 7, where solid and dashed lines are for experimental and theoretical data, respectively. Figures 7(a) and (b) show the $\sigma(V = 0)$ vs. ϕ_{bg} dependence for the short and the long sample, respectively. Also experimental data measured at 77 K and 300 K are shown. It is seen that the zero-bias conductivity increases slightly from 4 K to 77 K, and more significantly from 77 K to 300 K. The conductivity change is strongest near the CNP

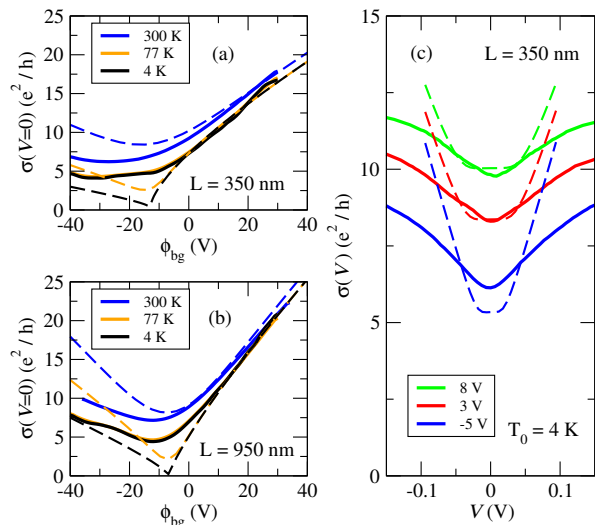


FIG. 7. Experimental results (solid lines) and a theoretical fit (dashed lines) for a short BLG sample ($L = 350$ nm) and a long BLG sample ($L = 950$ nm). Left-hand panels (a,b) show the linear response conductivity at $T = 300$ K (top curve), 77 K, and 4 K (bottom curve), and the right-hand panel (c) shows the differential conductivity for $L = 350$ nm at $T_0 = 4$ K and at gate voltages 8 V (top curve), 3 V, and -5 V (bottom curve). The parameters used for the theoretical fit are: $\mu_{eq} = 0.05$ eV, $n_{imp} = 7.0 \cdot 10^{16} \text{ m}^{-2}$, $\epsilon_r = 4.0$, $d = 210$ nm. For the short sample $L = 350$ nm and $n_{dop} = 10.0 \cdot 10^{15} \text{ m}^{-2}$, while for the long sample $L = 950$ nm, and $n_{dop} = 7.0 \cdot 10^{15} \text{ m}^{-2}$.

and also in the p -doped region. Since the theory is expected to work only in the absence of p - n junctions, the fitting is done only to the $\sigma(V = 0)$ vs. ϕ_{bg} data [Fig. 7(a,b)] at $\phi_{bg} > \phi_{bg,min}$, with $\mu_{eq} > 0$. The same parameters are then used for calculating $\sigma(V)$. The $\sigma(V)$ data for the short sample are shown in Fig. 7(c).

The parameters used for the fit are given in the caption of Fig. 7. The work function mismatch $\mu_{eq} = 0.05$ eV is of the correct sign and order expected for Ti/Al electrodes.¹⁴ A gate distance $d = 210$ nm is used, which is smaller than the experimental 270 nm. The smaller d used for the comparison is reasonable, since in the simplified geometry assumed by the theoretical model the gate potential is more strongly screened by the transport electrodes: even for the long sample the parallel plate limit is not fully reached.²² It is also notable that the average doping density $n_{dop} = 7\text{--}10 \cdot 10^{15} \text{ 1/m}^2$ is much smaller than the impurity density $n_{imp} = 7.0 \cdot 10^{16} \text{ 1/m}^2$, although the simplest theories for impurity doping predict these two to be equal.⁵ Even though we model, for simplicity, the impurities to be all similar and of the screened-Coulomb type (App. B), in reality there may be several different types of disorder⁶ present in our samples, which complicates the situation. The orders of magnitude $n_{dop}, n_{imp} \sim 10^{15}\text{--}10^{16} \text{ 1/m}^2$, are still in the range that can be expected from other experiments.^{4,6}

The overall agreement of the theory with the experiment is good, apart from the large deviations for

$\phi_{bg} \lesssim \phi_{bg,min}$, where some parts of the system are close to the CNP. At these gate voltages the low-temperature theoretical results for $\sigma(V = 0)$ tend to fall well below the experimental ones, whereas at 300 K the opposite is true. In addition to this the clearest discrepancy is that the self-heating predicted by the theory is too strong, as shown by the overly steep slope of $\sigma(V)$ in Fig. 7(c). Also, the slight decrease of the experimental slope with voltage is not captured. A proper explanation of these effects would require considering interactions of the electrons with phonons, particularly the remote interface phonons of the SiO_2 substrate.^{15,18} Another clear deviation is that the theoretical $\sigma(V)$ curves for high ϕ_{bg} tend to be flatter close to $V = 0$ than in the experiments. (The theoretical results for the long sample are otherwise similar as in Fig. 7(c), but even slightly more “flat”.) As suggested in Sec. II, the correct shape could presumably be reproduced by considering charge puddles, i.e., a non-uniform impurity density and doping. To keep the model simple and the number of fitting parameters small, we have neglected puddles here.

It should be noted the gross features of the results can be understood simply based on the temperature-dependence of the local conductivity,⁵ which may be worked out analytically [Eq. (B5) below] and the fact that the average temperature increases roughly linearly with the bias voltage. However, the precise shape of the nonlinearity is dependent on the various sources of nonuniformity.

IV. DISCUSSION

The heating effects described above are not the only possible sources of nonlinearity. As already mentioned, at high enough bias voltage electron scattering from phonons tends to reduce the conductivity, which is expected to make the current-voltage curves at high bias sublinear. This has been seen in MLG as a tendency for the current to almost saturate.^{9,10} We also see similar effects in our experiments²³ with BLG at voltages $V \gtrsim 0.1$ V.

The possibility of nonlinear $I(V)$ s in graphene at low bias have also been discussed based on simple arguments involving the energy-dependence of the number of open transport channels in the Landauer-Büttiker description of the linear-response conductivity.^{23–25} Such calculations are problematic for the prediction of current-voltage characteristics beyond linear response, however, since they do not consider the role of the actual voltage profiles.²⁴ Ideally, the electrostatic potential drop should be calculated self consistently, as we have done above.

Other mechanisms for nonlinear (mostly superlinear) current-voltage responses in graphene have very recently been discussed by many authors.^{11,26–31} In particular, Zener-Klein tunneling in MLG has been shown to give rise to superlinearities close to CNP.^{11,26,27} It seems unlikely, however, that a similar mechanism would be of

importance in our experiments, since the nonlinearity is weakly gate-dependent. Other possibilities for nonlinearities include the presence of tunnel junctions²⁸ or contact phenomena,²⁹ but we can disregard them as an explanation of our measurements due to the weak length-dependence of the nonlinear conductivity $\sigma(V)$. Furthermore, nonlinear current-voltage curves in graphene oxides have been explained with space-charge limited currents,³⁰ but such effects are likely to be negligible in metallic graphene, as also supported by the absence of any bias-doping effects in our simulations. Nonlinearities are predicted also for vertical transport in misaligned BLG or few-layer systems.³¹ However, of all these possibilities the self-heating scenario presented above seems to be the most likely explanation of our experimental results.

To summarize, we have shown how Joule heating can contribute to the shape of the observed current-voltage characteristics of bilayer graphene in the diffusive limit. The heating is signified by a strong superlinear contribution in $I(V)$ and thus a low-bias differential conductivity $\sigma(V)$ increasing with V . Our experimental results and our numerical calculations are in good overall agreement for bias voltages $V \lesssim 0.1$ V. The heating effect is much

stronger in bilayer graphene than in monolayer, as can be expected from the differences in their electronic structures.

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Appendix A: Green function and characteristic functions

The Green function $G(x, y; x', y')$ of the Laplace operator satisfies $\nabla^2 G(x, y; x', y') = \delta(x - x')\delta(y - y')$, $G(x', y'; x, y) = G(x, y; x', y')$ and zero boundary conditions on the electrodes. For the particular geometry under consideration (Fig. 1) the Green function may be found analytically using conformal mapping techniques and it is

$$G(x, y; x', y') = \frac{1}{2\pi} \ln \sqrt{\frac{(\sin \tilde{x} \cosh \tilde{y} - \sin \tilde{x}' \cosh \tilde{y}')^2 + (\cos \tilde{x} \sinh \tilde{y} - \cos \tilde{x}' \sinh \tilde{y}')^2}{(\sin \tilde{x} \cosh \tilde{y} - \sin \tilde{x}' \cosh \tilde{y}')^2 + (\cos \tilde{x} \sinh \tilde{y} + \cos \tilde{x}' \sinh \tilde{y}')^2}}, \quad (\text{A1})$$

where $\tilde{x} = \pi x/L$, $\tilde{y} = \pi y/L$ and so on.

The characteristic function ψ_X for electrode X is defined such that it satisfies the Laplace equation $\nabla^2 \psi_X = 0$ with the boundary condition that $\psi_X = 1$ on electrode X and $\psi_X = 0$ on the other electrodes. Once the Green function is known, the characteristic functions may be easily represented in terms of it:

$$\begin{aligned} \psi_l(x, y) &= - \int_0^\infty dy' \frac{\partial}{\partial x'} G(x, y; x', y')|_{x'=-L/2} \\ \psi_r(x, y) &= \int_0^\infty dy' \frac{\partial}{\partial x'} G(x, y; x', y')|_{x'=L/2} \\ \psi_{bg}(x, y) &= - \int_{-L/2}^{L/2} dx' \frac{\partial}{\partial y'} G(x, y; x', y')|_{y'=0}. \end{aligned} \quad (\text{A2})$$

Appendix B: Charge concentration and transport coefficients for graphene

In our semiclassical model the charge density is assumed to be of the form

$$n(x) = \int_{-\infty}^{\infty} dE \mathcal{D}_\varphi(E, x) [f(E - \mu(x), T(x)) - \theta(E_D(x) - E)], \quad (\text{B1})$$

where $f(E, T) = 1/(e^{E/k_B T} + 1)$ is the Fermi function, $E_D(x) = -e\varphi(x)$, and we define $\mathcal{D}_\varphi(E, x) = \mathcal{D}(E + e\varphi(x))$, where $\mathcal{D}(E)$ is the density of states (DOS). Using Eq. (B1) self consistently in the Poisson equation is essentially the Thomas-Fermi approximation.¹⁴

Assuming a diffusive system with only elastic impurity scattering the transport coefficients are given by

$$\begin{aligned} \sigma(x) &= \int dE \sigma_\varphi(E, x) F(E - \mu(x), T(x)) \\ \kappa(x) &= \frac{k_B}{e^2} \int dE \sigma_\varphi(E, x) \frac{(E - \mu(x))^2}{k_B T(x)} F(E - \mu(x), T(x)) \\ \gamma(x) &= \frac{k_B}{e} \int dE \sigma_\varphi(E, x) \frac{E - \mu(x)}{k_B T(x)} F(E - \mu(x), T(x)), \end{aligned} \quad (\text{B2})$$

with $\alpha(x) = T(x)\gamma(x)$. Here $F(E, T) = -\partial f(E, T)/\partial E$ is the thermal broadening function, and we define $\sigma_\varphi(E, x) = \sigma(E + e\varphi(x))$, where $\sigma(E) = e^2 D(E) \mathcal{D}(E)$ is the energy-dependent Boltzmann conductivity. The quantity $D(E) = v^2(E)\tau(E)/2$ the diffusion constant, where $v(E)$ is the group velocity and $\tau(E)$ the transport relaxation time.

It is easy to see by change of the integration variable that the quantities in Eqs. (B1) and (B2) only depend on

the difference $\mu(x) - E_D(x)$. Thus below we define the “hatted” quantities with $n(x) = \hat{n}(\mu(x) - E_D(x), T(x))$, $\sigma(x) = \hat{\sigma}(\mu(x) - E_D(x), T(x))$, and similarly for the other transport coefficients.

As a specific model for the impurity scattering we consider only screened Coulomb impurities, which lead to a linear dependence of the conductivity on charge density⁵ for both BLG and MLG, as observed in most experiments.⁴ (For BLG also short-range scattering may be of importance.⁶) For simplicity we assume all of the bare impurities to carry a charge $\pm e$ and to be at zero distance from the graphene, and perform an average with respect to their positions.⁵ For BLG and MLG some further approximations are made, as explained below.

1. Bilayer graphene

For BLG we assume a purely parabolic and gapless dispersion $E = \pm(\hbar v_0 k)^2/\gamma_1$, where $v_0 = 10^6$ m/s and $\gamma_1 = 0.4$ eV. This yields a group velocity $v(E) = 2v_0\sqrt{|E|/\gamma_1}$ and a constant DOS $\mathcal{D}(E) = \frac{1}{\pi} \frac{\gamma_1}{(\hbar v_0)^2}$. Then

$$\hat{n}(\mu, T) = \frac{1}{\pi} \frac{\gamma_1}{(\hbar v_0)^2} \mu. \quad (\text{B3})$$

The DOS leads to an inverse Thomas-Fermi screening length $q_{TF,BLG} = 2e^2\gamma_1/[4\pi\epsilon(\hbar v_0)^2] \sim 1 \text{ nm}^{-1}$.

For the charged impurity scattering we use the “complete-screening” approximation.⁵ Thus we find $\tau(E) = \frac{4\hbar}{\pi^2} \frac{\gamma_1}{(\hbar v_0)^2} \frac{1}{n_{imp}}$, where n_{imp} is the average impurity density. This yields

$$\sigma(E) = C_{BLG}|E|, \quad C_{BLG} = \frac{8e^2\gamma_1}{\pi\hbar^3v_0^2n_{imp}}. \quad (\text{B4})$$

Then the transport coefficients are

$$\begin{aligned} \hat{\sigma}(\mu, T) &= C_{BLG} 2k_B T \ln \left(2 \cosh \frac{\mu}{2k_B T} \right) \\ \hat{\kappa}(\mu, T) &= \mathcal{L} T C_{BLG} \frac{3}{\pi^2} k_B T h(\mu/k_B T) \\ \hat{\gamma}(\mu, T) &= C_{BLG} 2k_B T \left[-\frac{\mu}{k_B T} \ln(2 \cosh(\frac{\mu}{2k_B T})) \right. \\ &\quad \left. + \text{Li}_2(-e^{-\mu/k_B T}) - \text{Li}_2(-e^{\mu/k_B T}) \right], \end{aligned} \quad (\text{B5})$$

where $\mathcal{L} = \frac{\pi^2}{3} \frac{k_B^2}{e^2}$ is the Lorenz number. Here and Li_2 is the dilogarithm function.³² and $h(a) = h(-a)$ is defined as

$$h(a) = \int_{-\infty}^{\infty} |x|(x-a)^2 \left[-\frac{d}{dx} \frac{1}{e^{x-a} + 1} \right] dx. \quad (\text{B6})$$

This function has the limits $h(a) \approx \frac{\pi^2}{3} 2 \ln(2 \cosh(a/2))$, when $|a| \gg 1$, and $h(a) \approx 9\zeta(3)$, when $|a| \ll 1$. Using these we see that the Wiedemann-Franz law $\kappa = \mathcal{L} T \sigma$ only applies if $|\mu| \gg k_B T$.

2. Monolayer graphene

For MLG the dispersion relation is $E = \pm\hbar v_0 k$, giving a constant group velocity $v(E) = v_0 = 10^6$ m/s, and a density of states $\mathcal{D}(E) = \frac{1}{\pi} \frac{2|E|}{(\hbar v_0)^2}$. Then

$$\hat{n}(\mu, T) = \frac{1}{\pi} \frac{2(k_B T)^2}{(\hbar v_0)^2} g(\mu/k_B T). \quad (\text{B7})$$

Here we have defined the function $g(a) = \text{Li}_2(-e^{-a}) - \text{Li}_2(-e^a) = -g(-a)$, which has the limits $g(a) \approx a|a|/2$, when $|a| \gg 1$, and $g(a) \approx 2 \ln(2)a$, when $|a| \ll 1$. The inverse screening length is now $q_{TF,MLG} = 4k_F e^2/(4\pi\epsilon\hbar v_0)$, with $k_F = |\mu|/(\hbar v_0)$.

For the impurity scattering we now assume that the “effective fine-structure constant”^{3,5} of MLG is small, $r_s = q_{TF,MLG}/(4k_F) = e^2/(4\pi\epsilon\hbar v_0) \ll 1$. (For SiO₂ $\epsilon = 4.0$, and $r_s \approx 0.5$.) In this way we find $\tau(E) = \frac{1}{n_{imp}} \frac{\hbar}{\pi^2} \frac{|E|}{(\hbar v_0)^2} \frac{1}{r_s}$. These give

$$\sigma(E) = C_{MLG}|E|^2, \quad C_{MLG} = \frac{e^2}{\pi^3 r_s^2 \hbar^3 v_0^2 n_{imp}}. \quad (\text{B8})$$

The transport coefficients are thus

$$\begin{aligned} \hat{\sigma}(\mu, T) &= C_{MLG} \left[\mu^2 + \frac{\pi^2}{3} (k_B T)^2 \right] \\ \hat{\kappa}(\mu, T) &= \mathcal{L} T C_{MLG} \left[\mu^2 + \frac{7\pi^2}{5} (k_B T)^2 \right] \\ \hat{\gamma}(\mu, T) &= \frac{2\pi^2}{3} C_{MLG} \mu k_B T. \end{aligned} \quad (\text{B9})$$

Note again that the Wiedemann-Franz law $\kappa = \mathcal{L} T \sigma$ is only approximately valid in the limit $|\mu| \gg k_B T$.

Appendix C: Low-bias resistance of p - n junction: classical thermal activation vs. quantum tunneling

In order to understand the temperature-dependence of the conductivity in Fig. 2 at $\phi_{bg} \ll \phi_{bg,min}$, we discuss some analytical results for the semiclassical conductance of a p - n junction in BLG or MLG. The existence of a p - n junction at location $x = x_0$ means that $\mu_{eq} - E_D(x_0) = 0$. At low temperature we linearize $E_D(x)$ around this point, such that $\mu_{eq} - E_D(x) \approx -A_1(x - x_0)$, where $A_1 = E'_D(x_0)$. The classical linear-response conductance for width W is then $G = W(\int_{-\infty}^{\infty} \rho(x) dx)^{-1}$, where $\rho(x) = [\hat{\sigma}(\mu_{eq} - E_D(x), T)]^{-1}$.

1. BLG

In this case $\hat{\sigma}(\mu, T)$ is given by Eq. (B5). Since we use the parabolic-band approximation, the x integral diverges logarithmically and a cutoff length L_c is needed,

which should be on the order of L . In this way, the conductance of a p - n junction (width W) may be approximated with

$$G \approx \frac{C_{BLG} A_1 W}{2 \ln(A_1 L_c / 2k_B T)}. \quad (C1)$$

The temperature-dependence has a logarithmic singularity at $T = 0$. This is the behavior seen in Fig. 2(a) at $\phi_{bg} \ll \phi_{bg,min}$.

Clearly the semiclassical result must break down at low enough temperature, in which case some quantum-mechanical result taking into account Zener-Klein tunneling is needed. The zero-temperature conductance would then remain finite. The simplest way to approximate the crossover temperature is to use a Wenzel-Kramers-Brillouin (WKB) approximation in a similar fashion as done for MLG.^{11,33,34} Estimates of this type show that the crossover temperature may well be on the order of room temperature. We note that such a calculation

predicts a superlinear current $I \propto V^a$ with $a = 4/3$, unlike in MLG where $a = 3/2$.

2. MLG

Here $\hat{\sigma}(\mu, T)$ is found from Eq. (B9). The p - n junction in MLG has a conductance

$$G = \frac{24k_B T C_{MLG} A_1 W}{\pi^3}. \quad (C2)$$

The linear temperature dependence is seen in Fig. 2(c) at $\phi_{bg} \ll \phi_{bg,min}$. At low temperature the p - n junctions completely dominate the conductivity of the entire sample. However, again, at low enough temperature this result breaks down. WKB estimates shows that this may occur already close to room temperature. Thus the Boltzmann calculations are only valid in the absence of p - n junctions.

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